

Supporting information

Water-Based Bi₂S₃ Nano-Inks Obtained with Surfactant-Assisted Liquid Phase Exfoliation and Their Direct Processing into Thin Films

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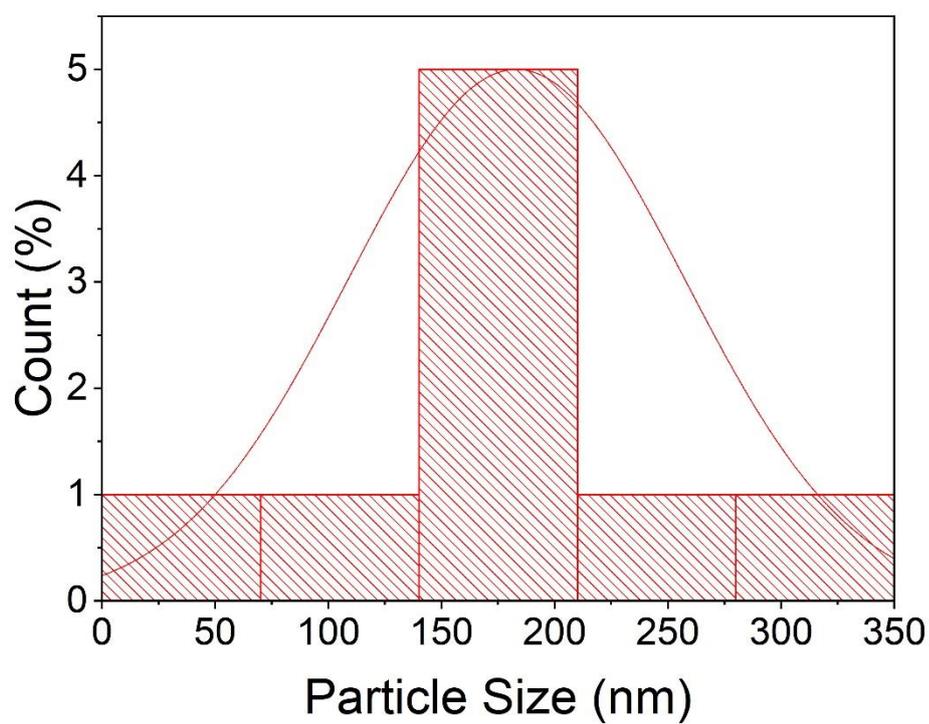
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Table S1: Parameters of LPE process

14	15	16	17	18	19	20	21	22	23	24	25	26	27	28	29	30	31	32
MC	Initial bulk concentration (mg/mL)	Surfactant	Surf. concentration (mM)	Exfoliation time														
			8.2															
			4.1															
Bi ₂ S ₃	10	SDS	2.0	3 h														
			1.0															
			0.5															
			8.2															
			4.1															
Bi ₂ S ₃	10	SDBS	2.0	3 h														
			1.0															
			0.5															
			8.2															
			4.1															
Bi ₂ S ₃	10	SHS	2.0	3 h														
			1.0															
			0.5															

Figure S1: Histogram of the distribution of particle size Bi_2S_3 

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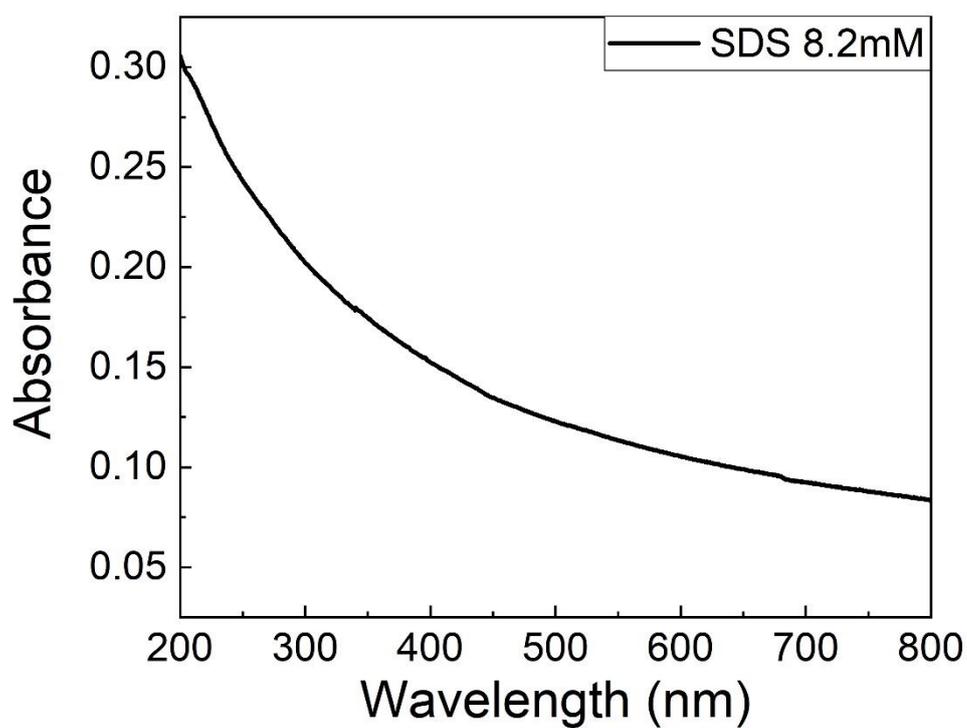
Figure S2: U-Vis spectrum of SDS 8.2mM.

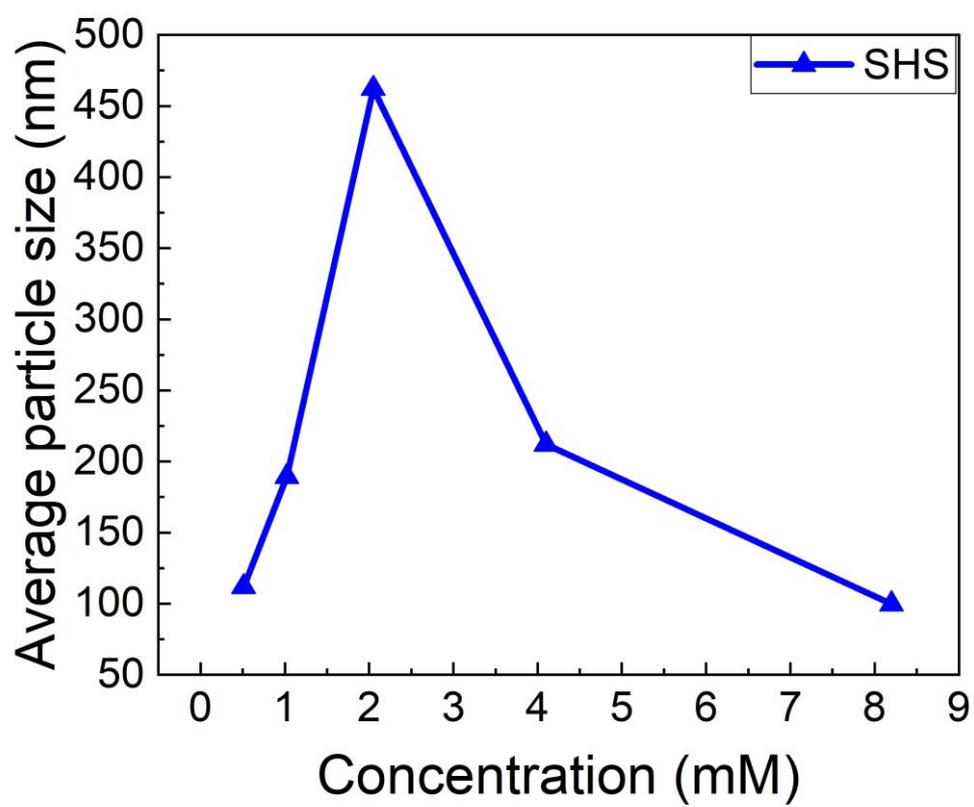
Figure S3: DLS of Bi₂S₃ SHS

Figure S4: SEM images of the Bi₂S₃ thin films with (a) 30 (b) 50 layers.

